

In the Specification

Page 1, after the title, insert the following new section:

CROSS REFERENCE TO RELATED APPLICATION

This is a 35 U.S.C. §371 application of and claims priority to PCT International Application Number PCT/EP2005/001797, which was filed February 22 2005, and was published in German, and which was based on German Patent Application No. 10 2004 009 239.7, filed February 26, 2004, and the teachings of all the applications are incorporated herein by reference.

The paragraph beginning at line 11 on page 2 is amended as follows:

With regard to the prior art, reference is made to ~~EP 1 107 089 A2~~
EP 1 107 039 A2, US 6,238,063 B1 and the Patent Abstract of Japan 01198759A.

After Claims, on page 17, please insert the following new section:

ABSTRACT

The invention relates to a system for reducing the coherence of a wave front-emitting laser radiation, especially for a projection lens for use in semiconductor lithography, wherein a first partial beam of a laser beam incident on a surface of a resonator body is partially reflected. A second partial beam penetrates the resonator body and emerges from the resonator body at least approximately in the area of entry after a plurality of total internal